Question Paper Code: U2524

Ph.D. COURSE WORK EXAMINATION, APRIL 2024

Elective

Communication Systems

21PCM524- VLSI DEVICE MODELING

(Regulations 2021)

Duration: Three hours Maximum: 100 Marks

Answer ALL Questions

PART - A $(5 \times 20 = 100 \text{ Marks})$

1. (a) Analyze the different voltage regions of CMOS models to reduce CO5- Ana (20) the noise in VLSI circuits with suitable techniques and choose the best region

Or

- (b) Analyze the various types of modes based on the supply CO5- Ana (20) voltage with respect to the threshold voltage and justify your answer.
- 2. (a) Derive the MOSFET Current Equation for different gate to source CO4- App (20) voltages under the conditions VGs>0.

Or

- (b) An NMOS transistor has the following parameters: $W = 10 \mu m$, L CO4- App (20) = 5 μm , VTO = 0.6V, $\gamma = 1.0$, $\varphi = 0.7$ V, $\mu n Cox = Kn = 50 \mu A V 2$. Plot the transfer characteristics (ID vs.VGB) of the transistor using the EKV model showing the conduction and saturation branch of the drain current.
- 3. (a) Analyze the Effect of scaling laws on MOSFET device circuit CO5- Ana (20) performance and choose the best.

Or

- (b) Analyze the Various techniques to scaling the MOSFET to CO5-Ana (20) optimize the area in VLSI circuits.
- 4. (a) Apply the Triangular Well Method in Quantum Phenomena for CO2- App (20) MOS Transistors to reduce DIBL.

- (b) Apply the suitable methods to avoid second order effects using the CO2- App (20) Quantum Phenomena techniques in MOS Transistors using the relevant parameters.
- 5. (a) Design Symmetric double gate MOSFET structure using non- CO4- App (20) classical SOI CMOS Techniques.

Or

(b) Design the High electron mobility transistor using device modeling CO4- App (20) techniques for reduce to Power dissipation.